Crestal Sinus Elevation for Simultaneous Implant Placement

Arun K Garg¹, Gregori M Kurtzman², Lanka Mahesh³

ABSTRACT

Insufficient crestal height may present in the posterior maxilla that will require osseous grafting to place implants. When sufficient height is present to stabilize the implant at placement, simultaneous sinus augmentation via a crestal approach with implant placement can be performed. The crestal approach when applicable has fewer complications then lateral sinus augmentation procedures and is more comfortable for the patient during the post operative period. This article shall describe the crestal sinus augmentation technique using special reamers that are free-handing drill depth. This technique was complex and required surgical skill with utilization being applied to any crestal height remaining from paper thin to varying residual thicknesses. The other technique was first reported by Summers in 1994 and used a crestal approach to simplify the surgical aspect. This was designed when there was a sufficient height to stabilize the implant at placement, but an additional height was needed to encompass the implant within the bone.

The crestal approach requires sufficient bone height to stabilize the implant as the implant is required in this technique to tent up the sinus membrane and allow the graft to mature into host bone to encompass the apical portion of the implant. It has been suggested that a minimum height of 4 mm is required to achieve that goal. Crestal bone height, hence, may be diminished from the superior direction (enlargement of the sinus) or from the inferior aspect of the ridge (periodontal bone loss). This can complicate implant placement due to insufficient available to house an implant. Short implants have been advocated for these clinical situations but may not be the approach desired or insufficient height may not be present to even place these short implants.

Two approaches have been reported in the literature to the increase crestal bone height so that sufficient bone height may allow implant placement. The lateral sinus augmentation was first reported in 1980 by Boyne related to the pioneering work performed by Tatum. This technique was complex and required surgical skill with utilization being applied to any crestal height remaining from paper thin to varying residual thicknesses. The other technique was first reported by Summers in 1994 and used a crestal approach to simplify the surgical aspect. This was designed when there was a sufficient height to stabilize the implant at placement, but an additional height was needed to encompass the implant within the bone.

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There is some consensus that a 4-mm increase in height can be achieved with the crestal approach. With other authors stating greater height increases are possible to a possible 10 mm gain. When less available initial crestal height presents, a lateral sinus augmentation should be considered a better approach. The crestal approach works well in single sites or two adjacent sites but may not be suitable when more than two adjacent implants are planned and grafting needed at each site. The crestal approach for sinus augmentation has demonstrated a clinical success of over 93% as reported in the literature. Typically, multiple adjacent sites will require graft placement medial to where the implants are being placed and elevation of the sinus membrane medially cannot be performed through the crestal osteotomy.

CASE REPORT

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Sinus Crestal Approach Kit

The Sinus Crestal Approach kit (ImplantVision, Miami, FL) contains all the tools required for a crestal sinus elevation from site preparation.
to graft placement into the elevated sinus prior to implant insertion (Fig. 1). Having all the necessary tools in a single kit allows the practitioner to improve surgical treatment efficiency and have the items easier to access during treatment.

An edentulous site to be treated, the initial osteotomy is made with a pilot drill (guide drill, Fig. 2 left) resulting in a 2 mm osteotomy. As recommended previously depth should be 2 mm shy of the measured sinus floor. Depth stoppers can be used on the guide drill to improve depth accuracy. When a thin ridge is present and a starter is desired to prevent jumping of the guide drill with the crest, a diamond reamer may be used. These diamond reamers are a ball diamond available in three diameters (Fig. 2 right). If crestal sinus elevation is to be performed at an immediate extraction site, following tooth extraction, the socket is cleaned of residual soft tissue with the diamond reamers. This eliminates any soft tissue that may hamper osseous contact with the implant surface. The diamond reamers are run in the surgical handpiece at 800–1,200 rpm.

Following initial site preparation, the site diameter is enlarged to less than the diameter of the implant planned for the site. This will allow the implant to exert some osseocompression upon placement and improve initial stability especially in the less dense bone of the posterior maxilla. To achieve this, sinus depth (SD) reamers are utilized (Fig. 3, left). These drills have a safe tip designed to elevate the sinus floor without tearing the sinus membrane due to its rounded safe-end (right)

Upon contact with it and avoid tearing the delicate membrane (Fig. 3 right). Length stoppers are provided in the kit and their designation indicates the depth the drill may enter the bone before the stopper prevents further advancement (Fig. 4). These start at 3 mm and increase in 1 mm increments to a maximum of 12 mm. The stoppers may also be used on the guide drill and hand instruments to guide depth when they are used. The SD reamer drill with a stopper may also be used to verify osteotomy depth in relation to the sinus floor by placement off the handpiece into the site and a radiograph taken.

Several hand instruments are provided in the kit. These include a sensor gauge that is used to explore the apical depth of the osteotomy for contact with the sinus membrane (Fig. 5A). The tip of the sensor gauge is domed to prevent inadvertent puncture of the sinus membrane when exploring the osteotomy. Stoppers may be used on the sensor gauge to increase gauging accuracy when desired. A depth gauge instrument with millimeter markings allows the verification of the osteotomy depth and can be used for measurements of film radiographs to determine the crestal height present (Fig. 5B). A bone syringe with a 2.5-mm barrel diameter aids in the placement of graft material into the void created by elevation...
of the sinus membrane (Fig. 5C). A double-ended bone packer with a 1-mm end and a 2.2-mm end that will accommodate the stoppers allows the practitioner to push the graft material apically into the elevated sinus area (Fig. 5D). It is important that sufficient graft is placed into the sinus void under the elevated membrane to ensure that the placement implant upon healing has its apical portion surrounded by the bone.

**Case Description**

A 62-year-old female presented with a missing right maxillary molar, stated a desire to replace the missing tooth with an implant. A radiograph was taken and it was determined that with sinus pneumatization, additional height would be needed for implant placement (Fig. 6). As 6 mm of crestal height was present, initial implant stability would allow a simultaneous crestal sinus lift with implant placement. The patient was scheduled for a crestal sinus augmentation and implant placement.

Local anesthetic was administered and an incision was started in the buccal sulcus of the second molar and continued forward as a crestal incision across the edentulous site (Fig. 7). A full-thickness envelope flap was elevated to expose the crest of the ridge (Fig. 8). A 4-mm stopper was placed on the guide drill and the initial pilot hole was created at the center of the edentulous site matching the long axis of the adjacent teeth. A SD reamer of a diameter of 3.7 mm with a 5-mm stopper was used to increase the osteotomy diameter (Fig. 9). The
Sensor gauge was used to explore the apical aspect of the osteotomy and verify that the sinus membrane had been exposed and the membrane was intact. This was followed up with an 8-mm stopper on the same SD reamer to elevate the exposed sinus membrane (Fig. 10). Again the sensor gauge verified that the membrane was intact.

Freeze-dried cortical allograft graft particles are placed into a sterile dish and flooded with sterile saline (Fig. 11A) to fully rehydrate the allograft material. After 5 minutes, excess saline is wicked from the rehydrated particles with a piece of sterile gauze (Fig. 11B). Carboxymethylcellulose and glycerin are added to the graft particles (Fig. 11C). These materials act as a binder for the graft particles, increasing its firmness, but provides some slipperiness to aid in placing it through the osteotomy into the elevated sinus space (Fig. 11D).

Various augmentation materials may be used in both crestal and lateral sinus augmentation procedures. Autogenous blood concentrates such as platelet rich plasma (PRP) have been reported in the literature as improving graft organization and bone development compared to the use of osseous graft materials alone.\(^{10-15}\) A 5-mm stopper was placed on the 2.2 mm end of the bone packer instrument (Fig. 12). PRP fibrin pieces were placed into the osteotomy (Fig. 13) and the bone packer was used to compress the graft into the elevated sinus (Fig. 14). This process with additional pieces of PRP fibrin was repeated until the instrument...
met resistance and the stopper was close to contact with the crest. This would indicate that the elevated area was filled with a graft material and no further material was needed.

An implant (ImplantVision) of 3.7 mm × 11.5 mm was placed into the osteotomy using the surgical handpiece (Fig. 15). The implant was placed to be flush with the crest (Fig. 16). The flap was repositioned to achieve primary closure and secured with sutures (Fig. 17). A periapical radiograph was taken to document the implant position, depth, and relation of the apical portion of the implant and elevated sinus graft around it (Fig. 18).
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CONCLUSION
Crestal sinus augmentation may be required to allow implant placement when sufficient crestal height is present to stabilize the implant placed simultaneously at the surgical appointment. This approach is less complicated than lateral sinus augmentation procedures with less patient postoperative issues. The illustrated kit and technique improve the clinical outcome with a decrease in membrane tearing. Those practitioners who are routinely placing single or two adjacent implants in the posterior maxilla should be prepared for the need for increasing crestal bone height through a crestal sinus approach.

REFERENCES